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(54) Title: SILYL ALKYL ESTERS OF ANTHRACENE-AND-PHENANTHRENE-CARBOXYLIC ACIDS

(57) Abstract: The invention relates to silyl alkyl esters, in particular of anthracene and phenanthrene carboxylic acids, a process for their preparation, compositions and polysiloxane compositions which contain the silyl alkyl esters and which can be used in particular in the semiconductor industry for the preparation of anti-reflective layers for photolithographic applications.